Electrical and photovoltaic properties of CuTPP/p-Si organic-inorganic hybrid heterojunction

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Abstract: Thin films of 5,10,15,20-Tetraphenyl-21H,23H-porphine copper(II), CuTPP were prepared by conventional thermal evaporation technique on p-Si substrates to form CuTPP/p-Si organic-inorganic hybrid heterojunction. The temperature-dependence of the electrical characteristics of the CuTPP/p-Si heterojunction in the temperature range of 298–353 K was studied. The barrier height and ideality factor of the heterojunction were determined as a function of temperature. It is noticed that the bias barrier height \( \Phi_b \) increases and the ideality factor \( m \) decreases by increasing the temperature. Such behavior can be attributed to barrier inhomogeneities by assuming a high mismatch in CuTPP /p-Si interface. The value of series (\( R_s \)) and shunt (\( R_b \)) resistances were determined using junction resistance and found to be a strongly temperature dependence of \( 1/C^2 \) with voltage shows a straight line at high frequency (1 MHz) indicating the formation of barrier between CuTPP and p-Si and the potential barrier height is about 0.92 eV at 298 K. The photovoltaic properties of CuTPP /p-Si heterojunction were investigated under illumination and the main important parameters such as open circuit voltage, \( V_{oc} \), and short circuit current, \( I_{sc} \), were found to be 0.289 V and 0.03 A, respectively.

Keywords: CuTPP thin film; Heterojunction; Photovoltaic

I. Introduction

Organic solar cells promise to open up new markets for solar energy, potentially powering everything from watches and calculators to laptop computers. Their flexibility and minimal weight will allow them to be placed on almost anything from tents that would provide power to those inside, to clothing that would power personal electronic devices. \[1\]–3\] Because of the growing demand for renewable energy sources, the manufacturing of solar cells and photovoltaic arrays has advanced considerably in recent years\[4\]. Hybrid solar cells combine advantages of both organic and inorganic semiconductors. Hybrid photovoltaics have organic materials that consist of conjugated polymers that absorb light as the donor and transport holes and inorganic materials in hybrid cells are used as the acceptor and electron transporter in the structure \[5\].

In the late 1960s it was discovered that illuminated organic dyes can generate electricity at oxide electrodes in electrochemical cells \[6\]. As early as 1993, natural porphyrins and chlorophylls were being studied in dye-sensitized solar cell (DSSC) \[7\]–\[8\] and interest in these dyes has continued to grow. Porphyrins are perfectly suited for their integration in light energy conversion systems. These colored macrocycles exhibit very attractive physical properties, particularly very high extinction coefficients in the visible and near IR regions, where the maximum of the solar photon flux occurs, that is necessary for efficient photon harvesting \[9\]. Porphyrinoid derivatives and their DSSC performances has been the subject of several reviews in the last few years covering most cyclic tetapyrrole derivatives \[10\]–\[11\].

In the present work the potential availability of the heterojunction based on CuTPP for photovoltaic application is presented. This work deals with the designing and characterization of the new type of heterojunction having configuration Au/CuTPP/p-Si/AI. The electronic parameters controlling the heterojunction performance, such as barrier height, ideality factor, series resistance and interface parameters were evaluated by current–voltage and capacitance–voltage measurements. Moreover, the photovoltaic properties have been investigated by I–V characteristics under illumination.

II. Experimental Details

Au/CuTPP/p-Si/AI heterojunction was prepared by using a polished and etching p-type single crystal silicon wafer with a thickness of 400 \( \mu \)m. The wafer was rinsed successively in distilled water for some time to remove any dust particles, followed by ethyl alcohol to remove any grease material and then washed in distilled water.
water. The silicon wafer was etched using CP4 etching solution for 1.5 min. Etching solution was prepared by adding 18 ml of HF acid to 1.5 ml of acetic acid and 57 ml Conc. HNO3. After etching, the silicon wafer was washed for two minutes by distilled water and then by ethyl alcohol. After which the silicon wafer was coated from one side by aluminum electrode using thermal evaporation technique to fabricate the ohmic contact. The coating unit is supplied with a quartz crystal monitor (FTM4, Edwards) to determine the rate of deposition. The other side of silicon wafer was coated by CuTPP thin film with thickness 700 nm and the other masked electrode Au was deposited onto CuTPP thin film as ohmic contact.

The dark current-voltage (I-V) characteristics of Au/CuTPP/p-Si/Al p-Si heterojunction at different ambient temperatures, ranged from 293 to 353 K, were measured by using a high impedance Keithley electrometers model 617. The capacitance-voltage (C–V) characteristics of fabricated Au/CuTPP/p-Si/Al p-Si heterojunction were measured at room temperature at 1MHz by using a computerized capacitance–voltage system, consisting of C-V meter (Model 4108) in air and at dark conditions, interfaced to a personal computer. The illuminated current–voltage characteristics of Au/CuTPP/p-Si/Al heterojunction were also measured by using Keithley electrometers model 617. The incident white light provided by halogen lamp of intensity 5mW/cm², falls normally through the gold window on the organic film. The intensity of the incident light is recorded by a digital light meter (Lutro-Model LX-107).

III. Results And Discussions

3.1 Dark current-voltage characteristics

Fig.1 shows a semi logarithmic plot of the forward and reverse currents versus the applied voltage of Au/CuTPP/p-Si/Al p-Si heterojunction in the temperature range 293 – 353 K. The values of the current increases as the temperature increase. The heterojunction exhibits rectification behavior showing a diode-like characteristic. The specific parameters of the heterojunction such as the diode quality factor (m), the rectification ratio (RR), the series resistance (R_s), the shunt resistance (R_sh), the barrier height at the interface of the junction (Φ_b) can de estimated from I-V characteristics curves. The maximum rectification ratio is observed at ±0.25V at room temperature condition as shown in Fig.2.

The junction resistance, R_j of Au/CuTPP/p-Si/Al p-Si heterojunction is determined from I-V characteristic curves according to following formula [12]:

\[
R_j = \frac{\partial V}{\partial I}
\]

By plotting the junction resistance, R_j, as an ordinate versus bias potential, the series, R_s, and the shunt, R_sh, resistances are estimated. Fig.3 shows that the junction resistance arrives to a nearly constant value under forward bias which is R_s. The same behavior occurs also under reverse bias potential leading to determination of R_sh. The estimated values of R_s and R_sh are found to be 42.864 and 96.341 kΩ, respectively.

The dark current-voltage characteristics are extremely useful for identifying the transport mechanisms operating conduction. Fig.4 shows the current–voltage (I–V) characteristics observed for the heterojunction under the forward bias at different temperatures. For each curve; there are two distinct voltage regions indicated that there are two different predominant conduction mechanisms. In the first low voltage region 0<V<0.2 Volt; as shown in Fig.4 the relation between lnI versus V is linear and the current of the Au/CuTPP/p-Si/Al device obeys the thermoionic emission over the organic/inorganic barrier in the heterojunction. According to this conduction mechanism, the heterojunction current is given by [13-14].

\[
I = I_{01} \left( \exp \left( \frac{qV}{m_f k_B T} \right) - 1 \right)
\]

where q the electric charge, k_B the Boltzmann’s constant, T the absolute temperature and m_f is the ideality factor which determined from the slope of the linear region of the forward bias ln (I)-V (Fig.4).

Fig.5 shows the ideality factor, m_f as a function of temperature, the figure indicated that the ideality factor decrease with increasing temperature in the range of temperature 293-353K. The value of m_f is higher than the unity which may be attributed to either recombination of free carriers in depletion region or the increase of diffusion current [15]. To confirm that the thermoionic emission, at the first low voltage region, is the operating mechanism more analysis must be carried out. According to the thermoionic emission the saturation current I_{01} is given by[13-14]:

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\[
\ln \left( \frac{I_{01}}{T^2} \right) = \ln C + \left[ -\frac{q\phi_{B0}}{k_B} \right] \frac{1}{T}
\]

(3)

Where \( \phi_{B0} \) is the effective barrier height at the CuTPP/p-Si interface at zero bias, C is a constant. The plot of \( \ln \left( \frac{I_{01}}{T^2} \right) \) versus 1000/T supports the thermoionic emission mechanism in the applied voltage range 0\(<V<0.2 \text{ Volt}, \) as shown in Fig.6. The effective barrier height, \( \phi_{B0} \), is determined as \(-0.37 \text{ eV} \) is calculated from the slope according to Eq.(3). It is well known the ideality factor in organic/inorganic heterojunction depends on electrode material [16], regardless that for barrier height.

Under high voltage region (V > 0.35V), the transport through organic materials is governed by space-charge limited currents (SCLC) mechanism is dominated in this voltage range, the current density will obey the following equation [17]

\[
J_{SCLC} = \frac{9}{8} \varepsilon_0 \theta \mu \frac{V^2}{d^3}
\]

(4)

where \( \varepsilon_0 \) is permittivity of free space of CuTPP, \( \mu \) is the carrier mobility, \( d \) is the film thickness and \( \theta \) is the trapping factor. Fig. 7 shows the semi logarithms of forward current versus applied voltage at different temperature. This relation shows power law dependence with order \( \approx 2 \) indicating that the SCLC with a single trap level is the dominant in this voltage range.

The trapping factor \( \theta \) is defined by the ratio of free charge to trapped charge and given by:

\[
\theta = \frac{N_v}{N_t} \exp \left( \frac{-E_t}{K_B T} \right)
\]

(5)

Where \( N_t \) is the total trap concentration at energy level \( E_t \) above the valence band edge and \( N_v \) is the effective density of states at the valence band edge. Fig. 8 shows the temperature dependence of \( \ln (I_j) \) in the space charge region. The trap level \( E_t \) is determined from the slope of the curves and has the value of 0.3 eV.

The dark reverse \( I_R-V \) characteristics at different temperatures are shown in Fig.9. The reverse current shows a small dependence on voltage, although it increases with temperature. This indicates that the reverse current should be limited by another transport mechanism. The junction leakage was primarily dominated by the generation and recombination of carriers in the Si substrate [18, 19]. The resulting reverse current from generation recombination of carriers is thermally activated and is governed by [20]:

\[
I_R = I_{OR} \exp \left( \frac{\Delta E}{k_BT} \right)
\]

(6)

where \( \Delta E \) is the carriers activation energy which determined from the slope of these straight line. The value of \( \Delta E \) is calculated and found to be 0.43. This value is nearly equal one half of the energy band of Si substrate (\( E_g(Si) = 1.1 \text{ eV} \))[19], which confirms that the temperature and voltage dependence of the dark reverse current is governed by generation and recombination of charge carriers in Si substrate rather than at organic–inorganic interface or organic material.

3.2 Capacitance-voltage characteristics

The dark capacitance–voltage characteristics of Au/CuTPPCl/p-Si/Al heterojunction were measured at room temperature (293 K). High frequency (1MHz) is used to investigate the device capacitance, because the data obtained from the C–V measurement in the low frequencies range represents the sum of the space charge capacitance and the interface capacitance. As the frequency increases, the interface capacitance contribution to the device capacitance decreases [21].

Fig. 10 shows the relation between measured capacitance, \( C \) versus the applied reverse voltage. The relation between the junction capacitance and the reverse applied potential of an abrupt junction can be given by [22]:

\[
C^2 = \frac{q \varepsilon_S N_v A^2}{2(V_{do} - V_{appl})}
\]

(7)

where \( \varepsilon_S \) is the dielectric constant of p-Si and \( V_{do} \) is the diffusion potential at zero bias. The inset of Fig.10 shows the plotting of \( 1/C^2 \) versus the reverse applied voltage. It is observed that \( 1/C^2 \) increase linearly by increasing the reverse applied voltage. The linearity of this relation indicates that the junction is considered as
an abrupt heterojunction. The diffusion potential determined from the extrapolation of the linear parts of $(1/C^2)$–V plot to the V axis value which is found to be 0.43eV. The doping concentration value is obtained from the slope and calculated as $5.9 \times 10^{21}$ m$^{-3}$.

The barrier height can be determined from the relation [23]:

$$\phi(C - V) = V_{do} + V_p$$  \hspace{1cm} (8)

where $V_p$ is the potential difference between the top of the valence band in the neutral region of p-Si and the Fermi level. The value of $V_p$ has been calculated as 0.228 eV [22]. Therefore, the barrier height of value0.65 eV. The discrepancy between the barrier height obtained from the (I–V) and that obtained from(C–V) may be due to existence of excess capacitance at the structure or presence of barrier height inhomogeneity [23]. The difference between calculated values of barrier heights suggested that the barriers are non-uniform.

### 3.3 Photovoltaic characteristics

I–V characteristic of Au/CuTPP/p-Si/Al heterojunction heterojunction measured at room temperature under illumination is shown in Fig.11. Under illumination, the light generates carrier-contribution photocurrent due to the production of electron-hole pairs as a result of the light absorption. As it can be seen from Fig.11; the values of open circuit voltage ($V_{oc}$), short circuit current ($I_{sc}$), voltage at maximum power ($V_m$) and current at maximum power point ($I_{mp}$) for the device are: 0.289V, 0.03mA, 0.16V and $I_{mp}=0.022mA$, respectively. The filling factor (FF) is given by $FF= V_m I_{mp} / V_{oc} I_{sc}$. The calculated value of FF is 0.39. The experimental power conversion efficiency of a solar cell is given by: $\eta = FF V_{oc} I_{sc} / A P_{in}$ where $I_{in}$ is illumination intensity $\approx 5mW/cm^2$ and A is the effective area=2mm$^2$. The calculated value of cell efficiency is 3.4%. The efficiency had been calculated without correcting for reflection or electrode absorption losses. The calculated parameters are compared with those other some solar cells based porphyrin systems are listed in Table1.

### IV. Conclusion

Organic–inorganic heterojunction Au/CuTPP/p-Si/Al was prepared using thermal evaporation technique. The I–V characteristics demonstrated a rectification behavior of p–n heterojunction. The basic diode parameters such as the ideality factor, series resistance and the barrier height were extracted from the I–V measurement of Au/CuTPP/p-Si/Al. There are two basic conduction mechanisms operating in Au/CuTPP/p-Si/Al heterojunction solar cell and they are depending upon applied potential. Thermionic emission conduction mechanism is operating in the lower voltage range ($0V\sim0.2V$); followed by SCLC with a single trap level in the potential range greater than 0.35V. The values of open circuit voltage, short circuit current and voltage at maximum power, current at maximum power, fill factor and power conversion efficiency of the device are: 0.28V, 0.03mA, 0.16V, 0.022mA, 0.39 and 3.4%, respectively.

### References

Table. 1 Parameters of some organic solar cells based on porphyrin system.

<table>
<thead>
<tr>
<th>Solar cell construction</th>
<th>( V_{oc} (V) )</th>
<th>Fill Factor</th>
<th>Efficiency%</th>
<th>Ref.</th>
</tr>
</thead>
<tbody>
<tr>
<td>Au/CuTPP/p-Si/Al</td>
<td>0.289</td>
<td>0.39</td>
<td>3.4</td>
<td>Present work</td>
</tr>
<tr>
<td>Al/TPP/Au</td>
<td>0.74</td>
<td>0.18</td>
<td>0.06</td>
<td>[24]</td>
</tr>
<tr>
<td>Au/TPP/p-Si/Al</td>
<td>0.25</td>
<td>0.37</td>
<td>2.45</td>
<td>[25]</td>
</tr>
<tr>
<td>Au/FeTPPCl/p-Si/Al</td>
<td>0.47</td>
<td>0.32</td>
<td>5</td>
<td>[19]</td>
</tr>
</tbody>
</table>

Figure captions:

Fig. 1 I-V characteristic in the dark at different temperature in forward and reverse bias.

Fig. 2 Relation between the rectification ratio, RR, and the bias potential for Au/CuTPP/p-Si/Al heterojunction diode.

Fig. 3 Relation between the rectification ratio, \( R_p \), and the bias potential for Au/CuTPP/p-Si/Al heterojunction.

Fig. 4 Dark I-V characteristics of CuTPP/p-Si/Al at different temperature in forward bias.

Fig. 5 Temperature dependence of ideality factor, \( m_1 \), for Au/CuTPP/p-Si/Al heterojunction.

Fig. 6 The plotting of ln saturated current divided by \( T^2 \) vs. 1000/T at the first region.

Fig. 7 Shows the semi logarithms of forward current verse semi logarithms applied voltage at different temperature.

Fig. 8 Temperature dependence of \( \ln(I_p) \) at 1 and 1.5 V

Fig. 9 Plot of \( \ln(I_p/T^2) \) vs. 1000/T.

Fig. 10 Plot of \( C^2-V_f \) characteristics of the Au/CuTPP/p-Si heterojunction.

Fig. 11 Current -voltage characteristics curve for Au/CuTPP/p-Si/Al p-Si heterojunction under illumination conditions at room temperature.
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Electrical and photovoltaic properties of CuTPP/p-Si organic-inorganic hybrid heterojunction

Fig. 7

![Graph showing I(V) characteristics at different temperatures (293 K, 313 K, 333 K, 353 K).](image)

V (Volt)

Fig. 8

![Graph showing ln(I) vs. 1000/T relationship for two voltages (1 Volt and 1.5 Volt).](image)

ln (I, A)

1000/T (K⁻¹)

Fig. 9

![Graph showing ln(I_V) vs. 1000/T relationship for different voltages (0.1 Volt, 0.3 Volt, 0.4 Volt, 0.6 Volt).](image)

ln (I_V, A)

1000/T (K⁻¹)

Fig. 10

![Graph showing C(V) relationship with inset showing details of the relationship.](image)

C (Farad)

V (Volt)
Fig. 11

$V_m = 0.16 \text{ V}$

$I_m = 0.022 \text{ mA}$

$F.F = 40\%$

$\eta = 3.4 \%$